

APR-12-2006 WED 04:03 PM BRIAN S STEINBERGER PA

FAX NO. 321 633 9322 APR 12 2006 02

Appl No.: 10/795,884

Atty. Dkt.
UCF287DIV

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : RICHARDSON
Serial No. : 10/795,884
Filed : 03/8/2004
TC/A.U. : 2882
Examiner : THOMAS
Docket No. : UCF287DIV
Customer No. : 23717
For : EUV, XUV, AND X-RAY WAVELENGTH SOURCES
CREATED FROM LASER PLASMA PRODUCED FROM
LIQUID METAL

Honorable Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

In response to the office action mailed January 12, 2006, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims, which begins on page 2 of this paper.

Remarks/Arguments begin on page 6 of this paper.